

## Wanhuida jointly hosts thematic salon with PatSnap

Time: June 13 2025

On Friday June 13, 2025, Wanhuida Intellectual Property and PatSnap jointly host a thematic salon focusing on the hot-button issues pertaining to patent assertion in the renewable energy and chemical industry at Wanhuida's Beijing premises at Yiyuan Office Building, Friendship Hotel.

The three-hour salon has over 100 participants tuning in either visually or in person.

The event is kicked off with a very informative presentation made by Wanhuida Partner Tang Tiejun. Tiejun shares insights on *"Patent Drafting Strategy: From the Perspective of Patent Invalidity Actions and Infringement Suits"*. By delving into the fundamentals required in maintaining the validity of a patent, she offers, from the case law perspective, key takeaways on how to preemptively install in the drafting process guardrails to fend off possible invalidity actions and infringement suits.

Tang Tiejun speaking

The firm's associate Guan Yue speaks on *"Preparation and Examination of Supplementary Experimental Data in Patent Administrative and Judicial Proceeding"*. Yue prepares the floor on the legislative framework and judicial practice surrounding the admission and scrutiny over supplementary experimental data, elaborates on the assessment methodology over the probative force of supplementary experimental data in proving technical disclosure, and dissects the distinction and association between experiment and intellectual property appraisal.

Guan Yue speaking

The event is well-attended by major players and start-ups in the renewable energy and chemical industry.

PatSnap is the leading provider of research and development (R&D) analytics, for analysing tech trends, driving innovation, market planning, competitor intelligence and maximising return on IP assets. Founded in 2007, PatSnap is used by R&D, business and IP professionals in thousands of commercial and not-for-profit organisations globally. It has offices in the UK, USA, Singapore and China.